PATENT APPLICATION TRANSMITTAL LETTER

(Large Entity)

Docket No. ITL.1054US (P17790)

TO THE COMMISSIONER FOR PATENTS

Transmitted herewith for filing under 35 U.S.C. 111 and 37 C.F.R. 1.53 is the patent application of:

Huey-Chiang Liou, Hai Deng, Wang Yueh, and Hok-Kin Choi

For: Langmuir-Blodgett Chemically Amplified Photoresist

CC:

Enclosed are:							
☑ Certificate of Mailing with Express Mail Mailing Label No. EV 337 932 581 US							
☐ A certified copy			application.				
☑ Declaration☑ Power of Attorned	⊠ Signed.	Unsigned.					
	ry Iosure Statemen	<u>t</u>					
☐ Preliminary Ame							
☑ Other: Assignm							
		CLAIMS A	S FILED				
For	#Filed	#Allowed	#Extra		Rate		Fee
Total Claims	15	- 20 =	0	х	\$18.00		\$0.00
Indep. Claims	3	- 3 =	0	х	\$86.00		\$0.00
Multiple Dependent Claims (check if applicable)							\$0.00
						BASIC FEE	\$770.00
					TOTAL	. FILING FEE	\$770.00
☑ A check in the a	mount of \$	770.00 to co	over the filing	fee is e	enclosed.		
☑ The Director is h	ereby authorized	I to charge and cr	-			20-1504	
as described be ☐ Charge	ow. the amount of	a	s filing fee.				
☑ Credit any overpayment.							
☑ Charge any additional filing fees required under 37 C.F.R. 1.16 and 1.17.							
☐ Charge the issue fee set in 37 C.F.R. 1.18 at the mailing of the Notice of Allowance,							
pursuar	t to 37 C.F.R. 1.3	311(b).			\sim)	
				/		200	
Dated: October 28, 2003 Signature Timothy/N. Trop/Reg. No. 28,994							
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